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1:1 and 1:2 Complexes of Bu_4NF and $\text{BF}_3\cdot\text{Et}_2\text{O}$: Unique Properties as Reagents for Cleavage of Silyl Ethers

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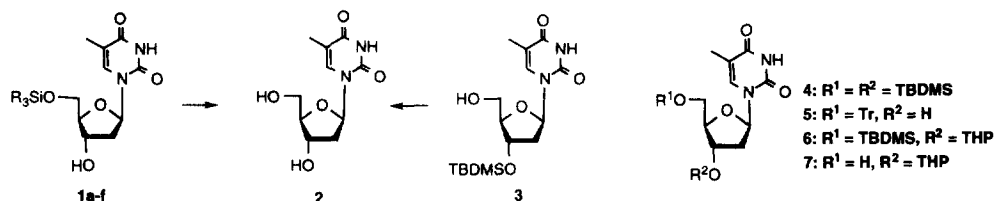
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Abstract: A new method for removal of trialkylsilyl groups from silyl ethers using Complex A and Complex B, generated from tetrabutylammonium fluoride (TBAF) and $\text{BF}_3\cdot\text{Et}_2\text{O}$ has been developed. The desilylation by use of these boron complexes is significantly affected by the steric factor on the Si atom and the reagent.

Silyl ethers have been widely used to protect hydroxyl groups in organic synthesis, because they can be prepared easily under mild conditions and selective silylation of primary hydroxyl groups can be utilized in the presence of secondary and/or tertiary alcoholic functions.¹ Sterically hindered trialkylsilyl groups such as TBDMS and *t*-butyldiphenylsilyl (TBDPS) have been often used as protecting groups that are stable under various conditions and cleaved by treatment with fluoride-ion sources such as tetrabutylammonium fluoride (TBAF) and HF-pyridine.² Silyl ether linkages have been also cleaved by using a variety of reagents involving Lewis acids and fluoride species such as $\text{BF}_3\cdot\text{Et}_2\text{O}$,³ SiF_4 ,⁴ H_2SiF_6 ,⁵ and LiBF_4 .⁶ A comprehensive review of silicon protecting groups has appeared in a book by Green and Wuts.^{1b}

In this paper, we report unique properties of 1:1 and 1:2 complexes of TBAF and $\text{BF}_3\cdot\text{Et}_2\text{O}$ as reagents for removal of trialkylsilyl groups from silyl ethers.

In connection with our oligoribonucleotide synthesis, we have needed milder reagents prescribed for removal of the 2'-TBDMS group from protected oligoribonucleotide blocks. Our particular interest was focused on the use of complexes of TBAF and $\text{BF}_3\cdot\text{Et}_2\text{O}$ which was first reported as reagents for deprotection of enol ether derivatives by Gevorgyan and Yamamoto.^{7,8} Consequently, we found that 1:1 and 1:2 complexes of TBAF and BF_3 , *i.e.*, complex **A** ($\text{Bu}_4\text{NF}\cdot\text{BF}_3\cdot\text{Et}_2\text{O}$) and complex **B** ($\text{Bu}_4\text{NF}\cdot 2(\text{BF}_3\cdot\text{Et}_2\text{O})$), exhibited intrinsic behavior different from the well known desilylating reagents above mentioned.



First, desilylation rate of 5'-O-TBDMS-thymidine (**1a**)⁸ in CH_3CN was examined under various conditions using 10 equiv of complex **A** or **B**. These results are summarized in Table 1. As the result, it was found that complex **A** cleaved **1a** faster ($t_{\text{comp}} = 10$ min) than TBAF, but more slowly than BF_3 and complex **B** (Entries 1, 2, 5, and 6). When the reaction was prolonged, some byproducts were considerably formed in the case of $\text{BF}_3\cdot\text{Et}_2\text{O}$ and complex **B** (Entries 2, 3, and 6). However, the use of the latter at a concentration of 0.1 M resulted in not only complete depression of such side reactions but also still rapid removal of the TBDMS

Table 1. Time Required for Removal of the TBDMS Group from 5'-O-TBDMS-T (1a) under Various Conditions^a

Entry	Reagent		Solvent	Reaction time (min)	
	Conc. (M)			t_{comp}	t_{dec}
1	TBAF	1.0	MeCN	40	
2	BF ₃ ·Et ₂ O	1.0	MeCN	<0.5	5 ^b /12 h ^c
3	BF ₃ ·Et ₂ O	0.1	MeCN	<0.5	60 ^b
4	Bu ⁺ N ⁻ BF ₄ ⁻	1.0	MeCN	no reaction (48 h)	
5	Complex A	1.0	MeCN	10	
6	Complex B	1.0	MeCN	<0.5	120 ^b
7	Complex B	0.1	MeCN	<0.5	
8	TBAF	1.0	THF	60	
9	BF ₃ ·Et ₂ O	1.0	THF	24 h	
10	Complex A	1.0	THF	180	
11	Complex B	1.0	THF	180	

^a All reactions were carried out in CH₃CN at r.t.

^b the time when a byproduct was detected.

^c the time required for complete decomposition.

Table 2. Time Required for Removal of Silyl Groups from 5'-O-Silylated-T (1a-f)^a

Entry	Silyl Ether	t_{comp} (min.)		
		TBAF	Complex A	Complex B
1	tBuMe ₂ Si 1a	40	10	<0.5
2				
3				
4	Ph ₂ MeSi 1b	<0.5	<0.5	<0.5
5				
6				
7	Ph ₃ Si 1c	<0.5	10	<0.5
8				
9				
10	ThexylMe ₂ Si 1d	60	60	2
11				
12				
13	iPr ₃ Si 1e	20	600	20
14				
15				
16	tBuPh ₂ Si 1f	60	$t_{1/2} = 12$ h	300
17				
18				

^a All reactions were carried out in CH₃CN at r.t.

group (Entry 7). In the present boron complex mediated desilylation, a remarkable solvent effect was observed. When THF was used as the solvent, the rate of desilylation using BF₃, complex A, or complex B was extremely decreased (Entries 9–11). The reason of this solvent effect might be due to unfavorable coordination of these boron reagents with THF having lone pair electrons.

Next, the relationship between the reaction time and the steric factor on the silicon atom was studied (Table 2). Diphenylmethylsilyl and triphenylsilyl ethers (**1b** and **1c**) were so unstable that cleavage of the O-Si bonds was too fast to detect an obvious difference in reaction rate between TBAF and complex B. Desilylation using complexes A and B was affected significantly by the steric hindrance on silicon. For example, complex A could cleave the O-Si bond of **1a** faster than TBAF (Entries 1, 2), but was considerably less reactive toward the 5'-O-triisopropylsilyl (TIPS) thymidine (**1e**) (Entries 13 and 14) and 5'-O-TBDPS-thymidine (**1f**) (Entries 16 and 17). On the other hand, complex B cleaved very effectively the O-Si bonds of **1a** (Entries 1 and 3) and 5'-O-dimethylhexylsilylthymidine (**1d**) (Entries 10 and 12), but slowly in the case of **1f** (Entries 16 and 18). These substituent effects can be explained in terms of the steric hindrance around the oxygen atom of silyl ethers (tBuMe₂Si ≤ ThexylMe₂Si < iPr₃Si < tBuPh₂Si) as well as the bulkiness of nucleophiles (F⁻ ≪ BF₄⁻ and B₂F₇⁻).

The rates of cleavage of the O-Si bond of 5'-O-TBDMS-thymidine (**1a**) and 3'-O-TBDMS-thymidine (**3**) were compared (Table 3). In both cases, complex A or B cleaved faster than TBAF (Entries 1 and 3 or Entries 5 and 7) even though the steric effect of desilylation on the rate is bigger in these boron complexes than in TBAF, so that the TBDMS group attached to the secondary hydroxyl group of **3** was removed much more slowly than that attached to the primary hydroxyl group of **1a** (Entries 6–8).

The remarkable effect of substituents on the Si atom could be applied to the selective Si-O bond cleavage of organic molecules having different silyl ethers. To test this possibility, chemoselective desilylation^{4,5b,6} of a 1:1 mixture of two silyl ethers was examined (Table 4). The rate of desilylation using complex B was so fast that the selective desilylation was achieved neither between **1a** and **3** (Entry 2) nor between **1a** and **1e** (Entry 4). Nonetheless, satisfactory selective desilylation of the TBDMS ether **1a** from a 1:1 mixture of **1a** and **1f** was conducted (Entry 6), resulting in 86% recovery of **1f**. It should be noted that complex A is more suitable for the selective removal of the TBDMS group of **1a** from a mixture of **1a** and **3**, as shown in Entries 1 and 2 of Table 5, because it reacts more slowly with silyl ethers. Similarly, 87% of **1e** could be recovered from a

Table 3. Comparison of the Time Required for Removal of the TBDMS Group from 5'-O-TBDMS-T (1a) with That of 3'-O-TBDMS-T (3)^a

Entry	Compd.	Reagent		<i>t</i> _{comp} (min.)
			Conc. (M)	
1	1a	TBAF	1.0	40
2	1a	Complex A	1.0	10
3	1a	Complex B	1.0	<0.5
4	1a	Complex B	0.1	<0.5
5	3	TBAF	1.0	60
6	3	Complex A	1.0	120
7	3	Complex B	1.0	10
8	3	Complex B	0.1	20

^aAll reactions were carried out in CH₃CN at r.t. using 10 equiv of reagent.

Table 4. Selectivity in Desilylation by Boron Complexes^a

Entry	Compd.	Reagent		Time min	Recovered compd. (%)
			Conc. (M)		
1	1a + 3	Complex A	1.0	15	3 (72)
2	1a + 3	Complex B	1.0	1	3 (22)
3	1a + 1e	Complex A	1.0	15	1e (87)
4	1a + 1e	Complex B	1.0	1	1e (30)
5	1a + 1f	Complex A	1.0	15	1f (89)
6	1a + 1f	Complex B	1.0	1	1f (86)
7	4	Complex A	1.0	15	3 (76)
8	1a + 5	Complex A	1.0	15	5 (9)
9	6	Complex A	1.0	15	7 (52)

^aAll reactions were carried out in CH₃CN at r.t. using 10 equiv of reagent. The reactions were quenched in the case of Entries 1-6 and 8 when one of the two components disappeared.

mixture of 1a and 1e after treatment with complex A for 15 min, when 1a disappeared completely. Treatment of a mixture of 1a and 1f with complex A gave also 89% recovery of 1f. Compound 3 was obtained in 76% yield by reaction of 3',5'-O-bis(*t*-butyldimethylsilyl)thymidine (4) with complex A (Entry 7).

The trityl group was lost considerably when the 5'-TBDMS group of 1a was deprotected from a mixture of 1a and 5'-O-tritylthymidine (5) by complex A, but ca. half of the 3'-THP group of 5'-O-TBDMS-3'-O-THP-thymidine (6) remained under the same conditions as shown in (Entries 8 and 9).

Before we started this study, *ab initio* calculations of BF₃, BF₄⁻, and B₂F₇⁻, the latter two of which might be produced from the 1:1 and 1:2 mixtures of TBAF and BF₃·Et₂O, were carried out at the MP2/6-31+G* level, in an attempt to expect the possibility of the present desilylation.¹⁰ The results of these calculations are summarized in Table 5.

Table 5. Eigenvalues of HOMO and LUMO and Net Atomic Charges of Boron Reagents of *ab initio* Calculation at the Level of MP2/6-31+G*

Reagent	Eigenvalues (au)		Net Atomic Charges (e)	
	HOMO	LUMO	B	F
BF ₃	-0.67	0.05	1.49	-0.35
BF ₄ ⁻	-0.39	0.22	1.80	-0.70
B ₂ F ₇ ⁻	-0.45	0.18	1.83	-0.64 ^a , -0.65 ^a -0.78 ^b

^a[E₃B-F-BE₃]⁻ ^b[F₃B-E-BF₃]⁻

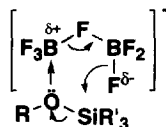


Fig. 2

approach of the boron atom of BF₄⁻ or B₂F₇⁻ to the electron-rich oxygen atom of silyl ethers by electrostatic interaction. On the other hand, B₂F₇⁻ has two kinds of electronegative fluorines (-0.64 and -0.65 e) similar to that of BF₄⁻ (-0.70 e). Moreover, it is likely that B₂F₇⁻ can form a six-membered ring intermediate with a silyl ether as shown in Fig 2. This study was actually done on the basis of these results and expectation.

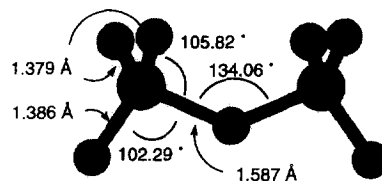


Fig. 1 The structure of B₂F₇⁻ proposed by *ab initio* calculation (MP2/6-31+G*)

The calculation of the ionic species B₂F₇⁻ converged to an optimized structure as shown in Fig. 1. Although BF₄⁻ and B₂F₇⁻ do not have unoccupied orbitals which can coordinate with the oxygen atom of silyl ethers, the atomic charges of the boron atoms in BF₄⁻ (1.80 e) and B₂F₇⁻ (1.83 e) are as electron-deficient as that of BF₃ (1.49 e). As the result, such a strong positive charge on the boron complexes enables the facile

However, it was found that commercially available Bu_4NBF_4 had no ability of cleaving **1a**, as shown in Entry 4 of Table 1.¹¹ Addition of Et_2O to Bu_4NBF_4 gave a similar result. These results imply that the active species in complex **A**, prepared by addition of $\text{BF}_3 \cdot \text{Et}_2\text{O}$ to Bu_4NF , is not Bu_4NBF_4 but something like $\text{TBAF} \cdot \text{BF}_3 \cdot \text{Et}_2\text{O}$ containing an ether ligand, as proposed originally by Gevorgyan and Yamamoto.^{7,11} Complex **B** might be composed of similar components having ether ligands. Moreover, the above *ab initio* calculation suggested that complex **B** might involve a new species having the B-F-B linkage as a possible component for the present desilylation.

The ^{19}F NMR (56.45 Hz, CFCl_3 as reference) spectrum of complex **B** in CD_3CN exhibited a broad resonance signal at -153.47, while complex **A** showed a similar but less broad resonance signal at -149.41 ppm. Contrary to these results, $\text{BF}_3 \cdot \text{Et}_2\text{O}$ exhibited a sharp resonance signal at -153.35 ppm. The broadening of the signals observed in complexes **A** and **B** implies that the complex **B** is in rapid equilibrium between the parent $\text{BF}_3 \cdot \text{Et}_2\text{O}$ and complex **A**, which is also in equilibrium between TBAF and $\text{BF}_3 \cdot \text{Et}_2\text{O}$. These results also suggested that the real species responsible for the present desilylation might be either the complexes themselves or two dissociated ones.

In conclusion, TBAF , complex **A** and **B** reacted with compounds having silyl ethers in the following order: TBAF ($i\text{Pr}_3\text{Si} > \text{TBDMS} > \text{ThexylMe}_2\text{Si} = \text{tBuPh}_2\text{Si}$); complex **A** ($\text{TBDMS} > \text{ThexylMe}_2\text{Si} > i\text{Pr}_3\text{Si} >> \text{tBuPh}_2\text{Si}$); complex **B** ($\text{TBDMS} > \text{ThexylMe}_2\text{Si} > i\text{Pr}_3\text{Si} >> \text{tBuPh}_2\text{Si}$). These inherent properties of the boron complexes described in this paper would provide a combined use of different silyl protecting groups for conversion of functional groups. Complex **B** would be a useful reagent for rapid removal of the TBDMS group, while complex **A** would be highly useful for selective removal of TBDMS ethers in the presence of $i\text{Pr}_3\text{Si}$ or tBuPh_2Si ethers.

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REFERENCES AND NOTES

1. a) Colvin, E. W. *Silicon Reagents in Organic Synthesis*; Academic Press: London, 1988. b) Greene, T. W. and Wuts, P. G. M. *Protective Groups in Organic Synthesis*; John Wiley and Sons, Inc.: New York, 1991.
2. a) Corey, E. J.; Venkateswararlu, A. *J. Am. Chem. Soc.* **1972**, *94*, 6190. b) Carpino, L. A.; Sau, A. *C. J. Chem. Soc., Chem. Commun.* **1979**, 514. d) Newton, R. F.; Reynolds, D. P.; Finch, M. A. W.; Kelly, D. R.; Roberts, S. M. *Tetrahedron Lett.* **1979**, *20*, 3981.
3. a) Barton, T. J.; Tully, C. R. *J. Org. Chem.* **1978**, *43*, 3649. b) Kelly, D. R.; Robert, S. M. *Synthetic Commun.* **1979**, *9*, 295.
4. Corey, E. J.; Yi, K. -L. *Tetrahedron Lett.* **1992**, *33*, 2289.
5. a) Pilcher, A. S.; Hill, D. K.; Shimshock, S. J.; Waltermire, R. E.; DeShong, P. *J. Org. Chem.* **1992**, *57*, 2492. b) Pilcher, A. S.; DeShong, P. *J. Org. Chem.* **1993**, *58*, 5130.
6. Metcalf, B. W.; Bukhart, J. P.; Jund, K. *Tetrahedron Lett.* **1980**, *21*, 35.
7. Gevorgyan, V.; Yamamoto, Y. *J. Chem. Soc., Chem. Commun.* **1994**, 59. In this paper, reagents of $\text{TBAF} \cdot \text{BF}_3$ in which the ratio of $\text{TBAF}:\text{BF}_3$ varied from 1:0.1 to 1:1.5, were used.
8. Gevorgyan, V.; Yamamoto, Y. *Tetrahedron Lett.* **1995**, *36*, 7765.
9. Hanessian, S.; Lavalee, P. *Can. J. Chem.* **1975**, *53*, 2975. New compounds **1c** and **1d** have mps of 126°C and $171\text{--}173^\circ\text{C}$, respectively (from CH_2Cl_2 -hexane). Compound **1b** was obtained as foam. These new compounds have satisfactory elemental analyses and were characterized by ^1H , ^{13}C NMR. Compounds **1b**, **1e**, and **1f** were synthesized by the literature method: Ogilvie, K. K. *Can. J. Chem.* **1973**, *51*, 3799; Ogilvie, K. K.; Donald J. I. *Tetrahedron Lett.* **1973**, *14*, 317; Ogilvie, K. K.; Thompson E. A.; Quilliam, M.A.; Westmore, J. B. *Tetrahedron* **1974**, *33*, 2865.
10. Calculation was performed on a Cray C916/12256 super computer by using Gaussian 94, Revision B.3: Frisch, M. J.; Trucks, G. W.; Schlegel, H. B.; Gill, P. M. W.; Johnson, B. G.; Robb, M. A.; Cheeseman, J.; Keith, T.; Petersson, G. A.; Montgomery, J. A.; Raghavachari, K.; Al-Laham, M. A.; Zakrzewski, V. G.; Ortiz, J. V.; Foresman, J. B.; Peng, C. Y.; Ayala, P. Y.; Chen, W.; Wong, M. W.; Andres, J. L.; Replogle, E. S.; Gomperts, R.; Martin, R. L.; Fox, D. J.; Binkley, J. S.; Defrees, D. J.; Baker, J.; Stewart, J. P.; Head-Gordon, M.; Gonzalez, C.; Pople, J. A.; Gaussian, Inc., Pittsburgh PA, 1995.
11. One of the referees kindly suggested this possibility.